

FIG. 1

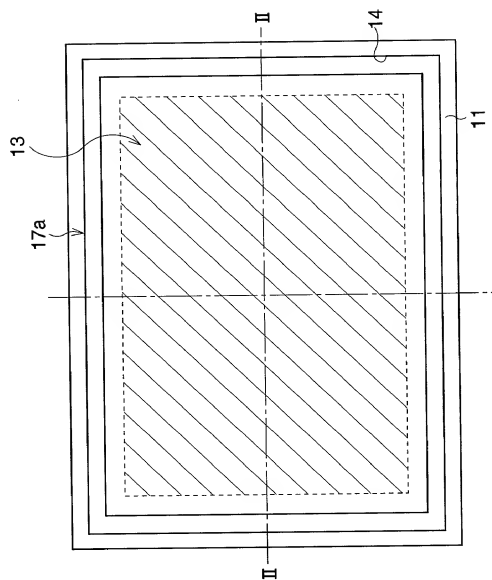


FIG. 2

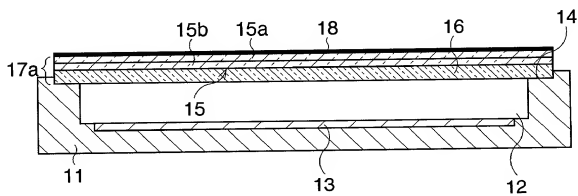


FIG. 3

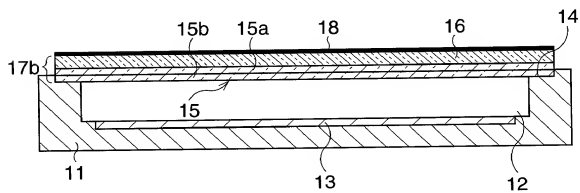


FIG. 4

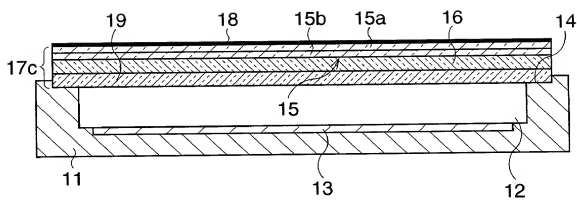


FIG. 5

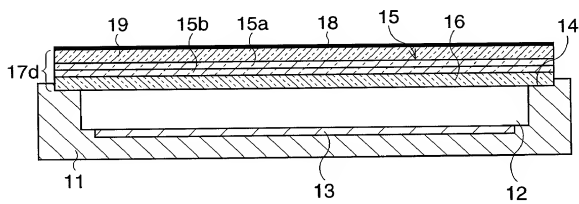


FIG. 6

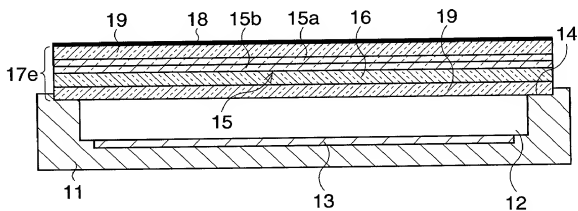


FIG. 7

	CONDITION OF DEPOSITION				PROPERTY OF FILM		
	VACUUM INTENSITY	TEMPERATURE OF LN PLATE	SPEED OF DEPOSITION	THICKNESS	FILM RESISTANCE	STATIC POTENTIAL BEFORE COATING	STATIC POTENTIAL AFTER COATING
EXAMPLE 1	2.0×10^{-5} torr	100°C	20nm/min	1.7nm	870k Ω	ABOUT 0.5kV	ABOUT 0.1kV
EXAMPLE 2	2.0×10^{-5} torr	100°C	3.3nm/min	3.3nm	ABOVE 40k Ω	ABOUT 0.5kV	ABOUT 1.0kV

FIG. 8

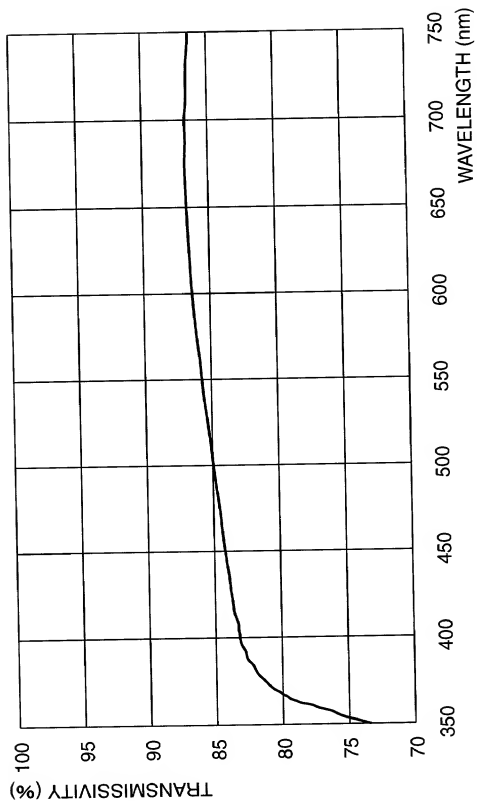


FIG. 9

